What is claimed is:

- 1 1. A light emitting device that emits visible light caused
- 2 by an ultraviolet ray from a discharge generated in a discharge
- 3 medium including a rare gas, the light emitting device
- 4 comprising:
- 5 a vessel that is hermetically sealed and contains the
- 6 discharge medium;
- a phosphorous material disposed in the vessel; and
- 8 one or more photocatalysts that (i) are disposed at one
- 9 or more first areas inside the vessel, the first areas being
- 10 reachable for one or both of the ultraviolet ray and light emitted
- 11 from the phosphorous material, and (ii) are in contact with the
- 12 discharge medium.
- 1 2. The light emitting device of Claim 1, wherein
- 2 the light emitting device is a plasma display panel,
- 3 the vessel is made of at least a first substrate and a
- 4 second substrate that oppose each other and are sealed together
- 5 around edges thereof,
- a plurality of ribs are formed on the first substrate,
- 7 in each of at least one of second areas provided between
- 8 the ribs, the phosphorous material forms one or more phosphor
- 9 layers on one or more walls that surround the second area, and

- 10 at least one of the photocatalysts is disposed at one
- or more positions selected from (i) anywhere in the second area
- 12 in which the phosphor layer is formed and (ii) at a top of at
- 13 least one of the ribs that sandwich the second area in which
- 14 the phosphor layer is formed.
- 1 3. The light emitting device of Claim 2, wherein
- 2 at least one of the photocatalysts is disposed so as to
- 3 be distributed throughout one or more of the phosphor layers.
- 1 4. The light emitting device of Claim 2, wherein
- 2 the phosphor layers are porous so as to allow the discharge
- 3 medium to pass through, and
- 4 at least one of the photocatalysts is disposed so as to
- 5 be (i) positioned between at least one of the phosphor layers
- 6 and the first substrate, and (ii) in contact with the at least
- 7 one of the phosphor layers.
- 1 5. The light emitting device of Claim 2, wherein
- 2 the phosphor layers are porous so as to allow the discharge
- 3 medium to pass through, and
- 4 at least one of the photocatalysts is disposed so as to
- 5 be (i) positioned between at least one of the ribs and the phosphor
- 6 layer formed over a surface thereof, and (ii) in contact with

- 7 this phosphor layer.
- 1 6. The light emitting device of Claim 2, wherein
- 2 at least one of the photocatalysts is disposed at one
- 3 or more positions selected from (i) at a top of at least one
- 4 of the ribs and (ii) in vicinity of such a top.
- 1 7. The light emitting device of any of Claims 3, 4, 5, and
- 2 6, wherein
- 3 when absorbing an ultraviolet ray, each phosphor layer
- 4 emits light in a color that is common to the phosphor layers
- 5 in that second area, the color being one of red, green, and blue,
- 6 and
- 7 at least one of the photocatalysts has an absorption edge
- 8 within a wavelength band of the color of blue in a visible light
- 9 range and is disposed in vicinity of the phosphor layer that
- 10 emits light in the color of blue.
- 1 8. The light emitting device of any of Claims 3, 4, 5, and
- 2 6, wherein
- 3 when absorbing an ultraviolet ray, each phosphor layer
- 4 emits light in a color that is common to the phosphor layers
- 5 in that second area, the color being one of red, green, and blue,
- 6 the photocatalysts each have an absorption edge in one

- 7 of two or more wavelength bands that are different from each
- 8 other, and
- 9 which wavelength band the absorption edge of each
- 10 photocatalyst is within is determined according to the color
- 11 of the light emitted from the phosphor layer that is disposed
- 12 in vicinity thereof.
- 1 9. The light emitting device of any of Claims 3, 4, 5, and
- 2 6, wherein
- 3 all the second areas each have at least one of the
- 4 photocatalysts disposed therein.
- 1 10. The light emitting device of any of Claims 3, 4, 5, and
- 2 6, wherein
- a main component of each of the photocatalysts is TiO₂
- 4 in anatase form.
- 1 11. The light emitting device of Claim 10, wherein
- 2 at least one of the photocatalysts has an absorption edge
- 3 within a visible light range.
- 1 12. The light emitting device of Claim 1, wherein
- 2 the light emitting device is a plasma display panel,
- 3 the vessel is made of at least a first substrate and a

- 4 second substrate that oppose each other and are sealed together
- 5 around edges thereof, and
- 6 the one or more photocatalysts are disposed outside an
- 7 image display area in which the phosphorous material is disposed.
- 1 13. The light emitting device of Claim 12, wherein
- 2 the photocatalysts are disposed in vicinity of the edges
- 3 of at least one of the first and the second substrates.
- 1 14. A method of manufacturing a light emitting device that
- 2 emits visible light caused by an ultraviolet ray from a discharge
- 3 generated in a discharge medium including a rare gas, the method
- 4 comprising:
- 5 a precursor preparing step of preparing a precursor of
- 6 a phosphor layer by mixing phosphor particles and a
- 7 photocatalyst;
- 8 a precursor disposing step of disposing the precursor
- 9 at one or more positions being reachable for the ultraviolet
- 10 ray, so that the precursor is in contact with the discharge medium;
- 11 and
- 12 a phosphor layer forming step of forming a phosphor layer
- 13 by baking the precursor.
 - 1 15. A method of manufacturing a light emitting device that

- 2 emits visible light caused by an ultraviolet ray from a discharge
- 3 generated in a discharge medium including a rare gas, the method
- 4 comprising:
- 5 a phosphorous material disposing step of disposing a
- 6 phosphorous material at one or more positions being reachable
- 7 for the ultraviolet ray; and
- 8 a photocatalyst disposing step of disposing a
- 9 photocatalyst at one or more positions being reachable for one
- 10 or both of the ultraviolet ray and light emitted from the
- 11 phosphorous material, so that the photocatalyst is in contact
- 12 with the discharge medium.
- 1 16. The method of any of Claims 14 and 15, wherein
- 2 a nitriding process is performed on the photocatalyst
- 3 in order to adjust an absorption edge of the photocatalyst.
- 1 17. A method of manufacturing a plasma display panel in which
- 2 a first substrate and a second substrate oppose each other and
- 3 are sealed together around edges thereof, the first substrate
- 4 having a plurality of ribs formed thereon, the method comprising:
- 5 a mixture preparing step of preparing a mixture of phosphor
- 6 particles and a photocatalyst;
- 7 a precursor disposing step of disposing the mixture in
- 8 at least one of areas provided between the ribs so as to form

- 9 a precursor of a phosphor layer on one or more of walls that
- 10 surround the area; and
- a phosphor layer forming step of forming the phosphor
- 12 layer by baking the precursor.
 - 1 18. A method of manufacturing a plasma display panel in which
 - 2 a first substrate and a second substrate oppose each other and
 - 3 are sealed together around edges thereof, the first substrate
- 4 having a plurality of ribs formed thereon, the method comprising:
- 5 a phosphorous material disposing step of disposing a
- 6 phosphorous material at one or more positions being reachable
- 7 for an ultraviolet ray; and
- 8 a photocatalyst disposing step of disposing a
- 9 photocatalyst at one or more positions on at least one of the
- 10 first substrate and the second substrate, the positions being
- 11 reachable for one or both of the ultraviolet ray and light emitted
- 12 from the phosphorous material, so that the photocatalyst is in
- 13 contact with a discharge medium in the plasma display panel.
 - 1 19. The method of any of Claims 17 and 18, wherein
 - a nitriding process is performed on the photocatalyst.